

LC cell is held @ a temperature
higher than a nematic isotropic
transition temperature T_{ni}

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1. (Amended) A method of manufacturing a liquid crystal display comprising the steps of:

forming a liquid crystal cell including the steps of:

providing an upper substrate and a lower substrate;

forming an alignment layer on at least one of the upper and lower substrates;

forming a sealant on at least one of the upper and lower substrates;

laminating the upper and lower substrates; and

injecting a liquid crystal layer between the upper and lower substrates;

heating the liquid crystal cell, wherein the heating step is performed at a temperature that is greater than about 10°C above a nematic-isotropic transition temperature; and

quickly cooling the liquid crystal cell.

14. (Amended) A method of manufacturing a liquid crystal display comprising the steps of:

forming a liquid crystal cell including the steps of:

providing an upper substrate and a lower substrate;

forming an alignment layer on at least one of the upper and lower substrates;

forming a sealant on at least one of the upper and lower substrates;

laminating the upper and lower substrates; and

injecting a liquid crystal layer between the upper and lower substrates; and

heating the liquid crystal cell, wherein the heating step is performed at a temperature that is greater than about 10°C above a nematic-isotropic transition temperature.

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